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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/790,492	03/01/2004	Lingyi A. Zheng	MIO 0082 N2/40509.292	9512
75	90 01/10/2006		EXAMINER	
DINSMORE & SHOHL LLP			THOMAS, TONIAE M	
One Dayton Cer Suite 500	ntre		ART UNIT	PAPER NUMBER
One South Main Street		2822		
Dayton, OH 45402-2023				

Please find below and/or attached an Office communication concerning this application or proceeding.

Application No. Applicant(s)				(: \$			
Examiner Toniae M. Thomas 2822 - The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE ② MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. Examinos of time may be available under the provisions of 37 CFR 1.135(b). In no event, however, may a reply be sinely flied If the period for reply specified above, the mainture standary priorition that standary minimum of thinky (30) days will be considered sinely. If the period for reply is period above, the mainture standary priorition that standary minimum of thinky (30) days will be considered sinely. If the period for reply specified above, the mainture standary priorition that standary minimum of thinky (30) days will be considered sinely. If the period for reply specified above, the mainture standary priorition and visit to the standary minimum of thinky (30) days will be considered sinely. If the period for reply specified above, the mainture standary priorition and visit to the standary priorition of the standary of the communication. Any reply received by the Office laths then there more into the maintain and the standary priorition and the standary priorition and the standary priorition is considered sinely. Any reply received by the Office laths then there more into the maintain and the standary priorition and the standary priority under 35 U.S.C. § 119 (a) (d) or (f). Application Papers 9 The specification is objected to by the Examiner. 10 The drawing(s) filed on 01 March 2004 (s/are: a) accepted or b) objected to by the Examiner. Application Papers 9 The specification is objected to by the Examiner. Note the attached Office Action or form PTO-152. Priority under 35 U.S.C. § 119 12 Acknowledgment i			Application No.	Applicant(s)) 			
Toniae M. Thomas Toniae M. Thomas Z822			10/790,492	ZHENG ET AL.				
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1)⊠ Responsive to communication(s) filed on 24 October 2005. 2a)⊠ This action is FINAL. 2b)□ This action is non-final. 3)□ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. Disposition of Claims 4)⊠ Claim(s) 1-11 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5)□ Claim(s) is/are allowed. 6)⊠ Claim(s) 1-11 is/are rejected. 7)□ Claim(s) is/are objected to. 8)□ Claim(s) are subject to restriction and/or election requirement. Application Papers 9)□ The specification is objected to by the Examiner. 10)☑ The drawing(s) filed on 01 March 2004 is/are: a)☑ accepted or b)□ objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11)□ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. Priority under 35 U.S.C. § 119 12)□ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a)□ All b)□ Some * c)□ None of: 1.□ Certified copies of the priority documents have been received. 2.□ Certified copies of the priority documents have been received in Application No 3.□ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17 2(a)). *See the attached detailed Office action for a list of the certified copies not received. Attachment(s) 11)□ Notice of Draftsperson's Patent Drawing Review (PTO-948) 32)□ Molice of Informal Patent Application (PTO-152)	THE - Exterent after - If the - If NC - Failu Any	MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period re to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing	36(a). In no event, however, may a reply be ting within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. (D) (35 U.S.C. § 133).				
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12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) ☐ All b) ☐ Some * c) ☐ None of: 1. ☐ Certified copies of the priority documents have been received. 2. ☐ Certified copies of the priority documents have been received in Application No 3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. Attachment(s) 1) ☐ Notice of References Cited (PTO-892) 2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) ☑ Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) 10 ☐ Notice of Informal Patent Application (PTO-152)	11)	The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form PTO-152.				
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DETAILED ACTION

1. This action is an official response to the amendment filed on 24 October 2005.

2. Currently, claims 1-11 are pending.

Information Disclosure Statement

3. A copy of each non-patent literature reference cited in the information disclosure statement (IDS) filed on 07 June 2004 was received along with a copy of the IDS on 24 October 2004. Accordingly, the non-patent literature references have been considered. See PTO-1449 attached hereto.¹

Terminal Disclaimer

- 4. The terminal disclaimer filed on 24 October 2005 disclaiming the terminal portion of any patent granted on this application, which would extend beyond the expiration date of US 6,551,893 has been reviewed and is NOT accepted.
 - a. The person who signed the terminal disclaimer is not recognized as an officer of the assignee, and he/she has not been established as being authorized to act on behalf of the assignee. See MPEP § 324.
- 5. An attorney or agent, not of record, is not authorized to sign a terminal disclaimer in the capacity as an attorney or agent acting in a representative capacity as provided by 37 CFR 1.34 (a). See 37 CFR 1.321(b) and/or (c).

¹ The US and foreign patent documents have been lined through in the attached PTO-1449 because each has been previously considered. See PTO-1449 attached to the Office action mailed on 22 July 2005.

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6. It would be acceptable for a person, other than a recognized officer, to sign a terminal disclaimer, <u>provided</u> the record for the application includes a statement that the person is empowered to sign terminal disclaimers and/or act on behalf of the organization.

Accordingly, a new terminal disclaimer including the above empowerment statement will be considered to be signed by an appropriate official of the assignee. A separately filed paper referencing the previously filed terminal disclaimer and containing a proper empowerment statement would also be acceptable.

Claim Objections

7. Claims 1-11 are objected to because of the following informalities: "nitrogen" should be deleted before the phrase "nitrogen-containing precursor" (each occurrence, e.g. claim 1, line 20). Appropriate correction is required.

Claim Rejections - 35 USC § 112

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

8. Claims 1-11 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claims 1 and 7-11 as submitted in the amendment filed on 24 October 2005 recite the limitation wherein a substantially flat temperature distribution is maintained across said semiconductor substrate as said silicon-containing

precursor is chemisorbed, and as said nitrogen-containing precursor is reacted with said chemisorbed silicon-containing precursor. The meaning of the word "flat" as it is used in the phrase "flat temperature distribution" is unclear. For purposes of examination, "flat" is interpreted to mean: constant or unvarying.

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Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which the subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 9. Claims 1 and 3-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Schuegraf et al. (US 5,624,865) in view of Lee et al. (US 2002/0068466 A1).

The Schuegraf et al. patent (Schuegraf) discloses a process for forming a memory cell (figs. 4-9 and accompanying text). The method comprises: forming a semiconductor structure defining a transistor 46 and a pair of transistor node locations 44 in a semiconductor substrate 40 (fig. 4 and col. 5, lines 5-8); forming an insulating layer 50 over the semiconductor substrate, wherein in one preferred embodiment the insulating layer is BPSG (fig. 5 and col. 5, lines 15-25); forming a container 54 in the insulating layer over one of the transistor node locations (fig. 5 and col. 5, lines 15-25); forming a polysilicon lower electrode layer 58 along an inner surface of the container, wherein in one

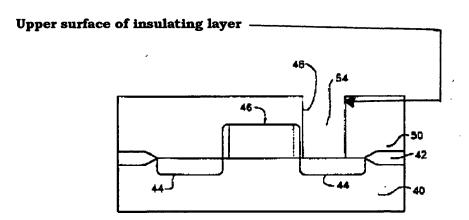
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19-21).

preferred embodiment the polysilicon is HSG polysilicon (fig. 6; col. 5, lines 27-34; and col. 5, lines 40-48); forming a dielectric layer 64 characterized by a given degree of uniformity over the polysilicon lower electrode layer and an upper surface of the insulating layer, wherein in a preferred embodiment the dielectric layer is a silicon nitride layer and has a thickness that is sufficient to prevent oxidation punch-through from a reoxidized layer 68 formed over the dielectric layer to the polysilicon lower electrode layer (fig. 8; col. 6, lines 1-4; col. 10, lines 9-11; and col. 6, lines 19-21); and forming an upper electrode layer 72 over the reoxidized layer 68 (fig. 9 and col. 6, lines 21-28). The silicon

The lower electrode layer 58 is formed so as to extend along an upper surface of the insulating layer 50 and from the inner surface 48 in the direction of the upper surface of the insulating layer along an extension of the container 54 (see fig. 7).

nitride layer may have a thickness less than about 50 angstroms (col. 6, lines



The dielectric layer 64 is formed on the lower electrode layer (see fig. 8).

Schuegraf lacks anticipation of forming the silicon nitride dielectric layer 64 through an atomic layer deposition (ALD) process, wherein a siliconcontaining precursor is chemisorbed over a surface of the lower electrode layer and a nitrogen-containing precursor is reacted with the chemisorbed siliconcontaining precursor to form the silicon nitride dielectric layer, and wherein a substantially flat temperature distribution is maintained across the substrate as the silicon-containing precursor is chemisorbed, and as the nitrogen-containing precursor is reacted with the chemisorbed silicon-containing precursor.

The Lee et al. pre-grant published application (Lee), on the other hand, teaches forming a silicon nitride dielectric layer through an ALD process (see figs. 2A-2F and accompanying text). Lee discloses an ALD method for depositing a silicon nitride layer, wherein after loading a semiconductor substrate into a reaction chamber (par. 25, lines 4-9), a silicon-containing precursor is chemisorbed over a surface of the substrate (fig. 2A and par. 25, lines 9-13), and then a nitrogen-containing precursor is reacted with the chemisorbed silicon-containing precursor to form a silicon nitride dielectric layer (fig. 2E and par. 27, lines 1-6). During the ALD process, the reaction chamber is maintained at a temperature of about 450°C (par. 25, lines 4-9), ergo a substantially flat or constant temperature distribution is maintained across the substrate while the silicon-containing precursor is chemisorbed over the substrate surface and while the nitrogen-containing precursor is reacted

with the chemisorbed silicon-containing precursor. The resulting silicon nitride is about 2 angstroms thick (par. 28, lines 1-11); however, the ALD process may be repeated until a desired thickness is achieved (par. 28, lines 4-11). Furthermore, the resulting silicon nitride layer is a high quality film having good step coverage (par. 28, lines 4-8).

As compared with conventional chemical vapor deposition (CVD) methods, for example low-pressure chemical vapor deposition (LPCVD), thin films deposited using ALD methods have excellent step coverage and uniformity (Lee - par. 3, line 8 - par. 5, line 7). Thus, it would have been obvious to one of ordinary skill in the art, at the time the invention was made, to modify Schuegraf by forming the silicon nitride layer using an ALD process, as taught by Lee, since thin films deposited using ALD have excellent step coverage and uniformity.

10. Claim 2 is rejected under 35 U.S.C. 103(a) as being unpatentable over Schuegraf in view of Lee as applied to claim 1 above, and further in view of Thakur (US 5,407,534).

Schuegraf lacks anticipation of forming the lower electrode layer such that it extends beyond the inner surface of the container. However, Thakur teaches forming a lower electrode layer such that it extends beyond the inner surface of a container (see figs. 2-4 and accompanying text). Thakur discloses a process for forming a capacitor, wherein the method comprises: forming a semiconductor structure defining a transistor 21 and a transistor node location

24 in a semiconductor substrate 20 (fig. 2 and col. 3, lines 33-35); forming a BPSG insulating layer 22 over the semiconductor substrate 20 (fig. 2 and col. 3, lines 35-38); forming a container in the insulating layer over the transistor node location (fig. 2 and col. 3, lines 38-39); and forming an HSG polysilicon lower electrode layer 23 along an inner surface of the container (figs. 2, 3 and col. 3, lines 39-51). The lower electrode layer 23 extends beyond the inner surface of the container (figs. 2, 3 and col. 3, lines 39-42).

Both Schuegraf and Thakur disclose a process for forming a memory cell in a dynamic random access memory (DRAM) device, the memory cell comprising a storage node capacitor, wherein the storage capacitor has as its storage node capacitor cell plate an HSG polysilicon lower electrode layer connected to a transistor node. As Thakur points out, "in dynamic semiconductor memory storage devices it is essential that storage node capacitor cell plates be large enough to retain an adequate charge (or capacitance) in spite of parasitic capacitances and noise that may be present during circuit operation" (Thakur - col. 1, lines 27-32). The surface area of the storage node capacitor cell plate is directly proportional to capacitance, that is, increasing the surface area of the cell plate increases capacitance ($C=\epsilon\epsilon_0 A/d$). Thus, it follows that forming the lower electrode layer to extend beyond the surface of the container increases the surface area of the cell plate and, thereby increases capacitance. Therefore, it would have been obvious to one of ordinary skill in the art, at the time the invention was made, to modify the

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combination of Schuegraf and Lee by forming the lower electrode layer so that it extends beyond the surface of the container, as taught by Thakur, since doing so increases the surface area of the storage node capacitor cell plate and thereby increases capacitance.

Double Patenting

11. The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. See *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970); and, *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent is shown to be commonly owned with this application (see 37 CFR 1.130(b)).

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

12. Claims 1-11 are rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 1-21 of U.S. Patent No. 6,551,893 B1 (Zheng et al.) in view of US Patent No. 5,407,534 (Thakur). The claimed invention in the Zheng et al. patent (Zheng) differs from the claimed invention in the current application in that the patented claims do not recite the limitation "wherein said lower electrode layer is formed so as to extend beyond said inner surface of said container." However, as explained

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above, Thakur teaches forming a lower electrode layer, such that extends beyond the inner surface of a container.

It would have been obvious, at the time the invention was made, to modify the Zheng patent by reciting the claim limitation "wherein said lower electrode layer is formed so as to extend beyond said inner surface of said container," as taught by Thakur, since this limitation offers the improvement of increased capacitance of the storage node capacitor.

Response to Arguments

13. Applicants' arguments filed on 24 October 2005 have been fully considered, but they are not persuasive.

In the remarks filed on 24 October 2005, Applicants argue against the Schuegraf et al., Lee et al., and Thakur references individually. Arguing against the prior art references individually is improper, since one cannot show nonobviousness by attacking references individually where the rejections are based on combinations of references (see *In re Keller*, 642 F.2d 413, 208 USPQ 871 (CCPA 1981); *In re Merck & Co.*, 800 F.2d 1091, 231 USPQ 375 (Fed. Cir. 1986)). Nevertheless, a response to Applicants' arguments follows.

Applicants argue that the cited references do not teach or suggest a substantially flat temperature distribution maintained across the substrate as the silicon-containing precursor is chemisorbed and as the nitrogen-containing precursor is reacted with the chemisorbed silicon-containing precursor. As explained above, the Lee et al. reference (US 2002/0068466 A1) discloses an

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ALD method for depositing a silicon nitride layer, wherein after loading a semiconductor substrate into a reaction chamber (par. 25, lines 4-9), a siliconcontaining precursor is chemisorbed over a surface of the substrate (fig. 2A and par. 25, lines 9-13), and then a nitrogen-containing precursor is reacted with the chemisorbed silicon-containing precursor to form a silicon nitride dielectric layer (fig. 2E and par. 27, lines 1-6). During the ALD process, the reaction chamber is maintained at a temperature of about 450°C (par. 25, lines 4-9), therefore a substantially flat or constant temperature distribution is maintained across the substrate while the silicon-containing precursor is chemisorbed over the substrate surface and while the nitrogen-containing precursor is reacted with the chemisorbed silicon-containing precursor.

Conclusion

14. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In

no event, however, will the statutory period for reply expire later than SIX

MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Toniae M. Thomas whose telephone number is (571) 272-1846. The examiner can normally be reached on Monday through Friday from 8:30 a.m. to 5:30 p.m.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Zandra Smith can be reached on (571) 272-2429. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

TMT 03 January 2006

> Mary Wilczewski Primary Examiner